Title: Human Heel Surrogate to Analyze Barefoot Slip

INVENTORS: Prof. Arnab Chanda, Centre For Biomedical Engineering KEYWORDS: Barefoot, Heel, Surrogate, Slip, Floor, Ergonomic DOMAIN: Material Science SUMMARY:

The development of a novel human heel surrogate that can precisely simulate the human heel properties, beneficial for the assessment of barefoot slipping risk. The surrogate is mounted on the slip-tester to understand and measure the biomechanical and frictional properties during heel and floor interaction, and to assess the barefoot slip risk. The slip-risk experiment was done on four different bathroom floors containing six different contaminants. It offers detailed insights into heel-floor interactions. Mimicking human slips recreates real-world scenarios, improving friction measurement accuracy, and gathering additional data for better ergonomic interventions against slipping accidents.

Surrogate Material and fabrication procedure

- 1. The human heel surrogate is fabricated using a biomimetic material.
- 2. A 3D scanner is used to capture the structural and surface properties of a foot, and then its surrogate is developed using a 3D printing device.
- An adaptor is also fabricated to give the necessary support to the surrogate during mounting on the slip tester



Figure: Skid tester used for slip testing and close up of the mounted heel surrogate for testing on contaminated floorings

ADVANTAGES:

- 1. The surrogate is made out of biomimetic material for precise simulation of biomechanical and frictional properties of the barefoot human heel skin.
- 2. The experiment performed on barefoot surrogates is essential for the selection of effective slip-resistant floorings for fall injury prevention.

APPLICATION:

- 1. Footwear Industry (comfort assessment for different footwear, and diabetic feet)
- 2. Application in testing flooring tiles for selection of suitable floor titles to prevent injury.

SCALE OF DEVELOPMENT: Functional prototype is available at lab scale

TECHNOLOGY READINESS LEVEL: TRL 4

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